



Semiconductor Materials for Photovoltaic Applications

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Inventors

Dr. John Kouvetakis

Professor

Department of Chemistry & Biochemistry, Arizona State University

Dr. Jose Menendez

Professor

Department of Physics, Arizona State University

Intellectual Property Status

Patent Pending

Contact

Bill Loux

Director of Business Development

Arizona Technology Enterprises, LLC (AzTE)

480.884.1996 main

480.884.1992 desk

Email: bloux@azte.com

Background

Crystalline Si has enjoyed spectacular success in the solar cell industry for various reasons including the ability to benefit from technological breakthroughs in the microelectronics industry and the close proximity of the 1.1 eV band gap value of Si to the optimal theoretical 1.3 eV band gap value for which the thermodynamically limited single-cell efficiency reaches a maximum value. Since modern single-cell crystal solar technology appears to be approaching the maximum expected efficiency, efforts to increase the competitiveness of these cells have focused on decreasing the cell thickness and thereby reducing silicon consumption. Still, ultra-thin Si cells face a fundamental limitation. The lowest energy direct optical transition in this material occurs at 3.5 eV, and therefore, its absorption below this threshold is very low because only phonon-assisted transitions are possible. On the other hand, thinner films have certain advantages because the ratio of carrier diffusion length to thickness is larger, thereby increasing the collection efficiency of minority carriers. The ideal compromise for maximum efficiency is estimated to be approximately 150 μm . Consequently, the industry is also approaching a fundamental limit when it comes to savings by reducing the Si thickness.

Invention Description

Researchers at Arizona State University have developed a method to fabricate Si/GeSn and/or Si/Ge tandem cells that take advantage of chemical vapor deposition (CVD) techniques allowing growth of Ge and GeSn on silicon substrates. The resulting potential efficiencies substantially exceed that of traditional Si solar cells and represent the most promising approach to advance Si-cell technology.

Potential Applications

- Commercial Electronic Devices
- Satellites, Spacecraft, Space Probes
- Remote and Grid-Tied Power Generation
- Remote Radiotelephones and Water Pumps
- Clothing

Benefits and Advantages

- **Offers Substantially Increased Efficiency** – traditional Si cells offer maximum thermodynamic efficiency of $\approx 35\%$ (requires thick Si) compared to $\approx 40\%$ efficiency offered by new method for ultra-thin Si; traditional Si operates at $\approx 21\%$ for actual commercial values and down to $\approx 15\%$ at a $25\mu\text{m}$ thickness
- **Allows Dramatic Reductions in Material Thickness** – GeSn/Ge thicknesses below $10\mu\text{m}$ and even below $1\mu\text{m}$ for certain applications sufficient for 90% light absorption compared to the optimal $150\mu\text{m}$ value needed for traditional Si solar cells
- **Eliminates Need for Light Trapping Features** – traditional methods require special texturing or rear surface reflectors; significance of advantage increases as thickness decreases